

RETROFIT SOLUTION ADVANCED DRYING

Significant reduction in solvent retention due to improved drying performance



Why Advanced Drying?

The all-too-familiar challenge: your CI flexo press could run much faster if drying was not the limiting factor. This is partly due to the strict requirements regarding the maximum solvent retention in the printed material and partly due to the drying temperatures, which are often limited by the substrates used.

Our „Advanced Drying“ retrofit solution is specifically designed to eliminate this limiting factor. Lengthening the web path in the drying tunnel improves drying performance, reduces solvent retention, and allows your printing presses to run at higher speeds. By lowering the drying temperature without sacrificing performance, this retrofit can also reduce energy consumption.

Quick and easy to retrofit into your existing W&H printing press. This retrofit solution is available for MIRAFLEX™ and NOVOFLEX™ CI flexo presses with drying tunnels in lengths of 4000 mm and 5300 mm.

Your advantages

- ✓ Better drying performance
- ✓ Reduction of the solvent retention by up to 60%
- ✓ Significant increase of production speed for jobs that are currently limited by drying
- ✓ Positive effect on carbon footprint: Temperature can be reduced with the same drying performance
- ✓ Energy savings
- ✓ Better performance with temperature-sensitive substrates



Learn more about **W&H Retrofit Solutions**:
https://www.wh.group/int/en/services/w_h_services/upgrades_retrofits/retrofit_solutions/retrofit_solutions_for_w_h_printing_presses.html